

## INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

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**SHAHAB et al**

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## U.S. PATENT DOCUMENTS

[illegible]

## FOREIGN PATENT DOCUMENTS

[illegible]

**OTHER DOCUMENTS** (including Author, Title, Date, Pertinent pages, etc.)

/C.J./	Sanders et al, "Self-segregating materials for immersion lithography", Advances in Resist Materials and Processing Technology XXV, Proc. of SPIE Vol. 6923, 692309 (2008).
/C.J./	<a href="http://www.dic.co.jp/en/products/fluoro/additive/appli.html">http://www.dic.co.jp/en/products/fluoro/additive/appli.html</a>

*Examiner	/Connie Johnson/ (08/23/2009)	Date Considered	08/23/2009
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Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.